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## **Electronic Supplementary Information**

## Rational manufacture of yolk-shell and core-shell metal oxide double layers from silicatemplated coordination polymer double layers

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\*Corresponding Author Telephone number: 82-2-2123-5637 Fax number: 82-2-364-7050 Email address: moh@yonsei.ac.kr **Preparation of silica@MCP (M = Er or Tb) with a thin or thick MCP layer.** *Silica@MCP with a thin MCP layer*: Solutions of M'(NO<sub>3</sub>)<sub>3</sub>:xH<sub>2</sub>O (0.080 mmol) in 4 mL of DMF and H<sub>2</sub>IPA (12.1 mg, 0.073 mmol) in 4 mL of DMF were prepared. Carboxylic acid-terminated silica (12 mg) was then added to the solution containing the metal ions and the resulting suspension was sonicated for 30 min. Subsequently, a DMF solution of H<sub>2</sub>IPA and 4 mL of THF were added to the resulting suspension. This mixture was placed in an oil bath (140 °C). After 20 min, the resulting product was collected by centrifuging and was washed several times with fresh DMF and ACN. *Silica@MCP with a thick MCP layer*: Solutions of M'(NO<sub>3</sub>)<sub>3</sub>:xH<sub>2</sub>O (0.170 mmol) in 4.5 mL of DMF and H<sub>2</sub>IPA (25.8 mg, 0.155 mmol) in 4.5 mL of DMF were prepared. Carboxylic acid-terminated silica (6 mg) was then added to the solution containing the metal ions and the resulting suspension was sonicated for 30 min. A DMF solution of H<sub>2</sub>IPA and 4.5 mL of THF were added to the resulting suspension. This mixture was placed in an oil bath (140 °C). After 20 min, the resulting product was collected by centrifuging and was washed several times with fresh DMF and ACN.

**Preparation of core-shell silica@MCP@GdCP (M = Er or Tb) with a thin or thick MCP layer.** 1: Solutions of Gd(NO<sub>3</sub>)<sub>3</sub>·*x*H<sub>2</sub>O (0.020 mmol) in 4 mL of DMF and H<sub>2</sub>IPA (2.99 mg, 0.018 mmol) in 4 mL of DMF were prepared. Single-layered silica@MCP with a thin MCP layer (4 mg) was then added to the solution containing the metal ions and the resulting suspension was sonicated for 30 min. A DMF solution of H<sub>2</sub>IPA and 4 mL of THF were added to the resulting suspension. This mixture was placed in an oil bath (140 °C). After 20 min, the resulting product was collected by centrifuging and was washed several times with fresh DMF and ACN. **2**: Solutions of Gd(NO<sub>3</sub>)<sub>3</sub>·*x*H<sub>2</sub>O (0.011 mmol) in 4 mL of DMF and H<sub>2</sub>IPA (1.66 mg, 0.010 mmol) in 4 mL of DMF were first prepared. Single-layered silica@MCP with a thick MCP layer (4 mg) was then added to the solution containing the metal ions and the resulting suspension was sonicated for 30 min. A DMF solution of H<sub>2</sub>IPA and 4 mL of THF were added to the resulting suspension. This mixture was placed in an oil bath (140 °C). After 20 min, the resulting product was collected by centrifuging and was washed several times with fresh DMF and ACN.



**Fig. S1.** IR spectra of (a) carboxylic acid-terminated silica, (b) H<sub>2</sub>IPA, (c) core–shell of silica@ErCP, and (d) silica-templated CP double layer of silica@ErCP@GdCP.



Fig. S2. SEM images showing the formation of (a) ErCP and (b) GdCP with large size distribution.



**Fig. S3.** SEM images of (a) carboxylic acid-terminated silica, (b) core–shell of silica@TbCP, and (c) silica-templated CP double layer of silica@TbCP@GdCP. EDX spectra of (a') carboxylic acid-terminated silica, (b') silica@TbCP, and (c') silica@TbCP@GdCP.



**Fig. S4.** SEM images of (a) carboxylic acid-terminated silica, (b) core–shell of silica@YCP, and (c) silica-templated CP double layer of silica@YCP@GdCP. EDX spectra of (a') carboxylic acid-terminated silica, (b') silica@YCP, and (c') silica@YCP@GdCP.



**Fig. S5.** (a) SEM image and (a') EDX spectrum of silica@YCP@GdCP. (b) SEM image, (b') EDX spectrum, (c) TEM image, and (d) PXRD pattern of yolk–shell-type metal oxide double layer of silica@Y<sub>2</sub>O<sub>3</sub>@Gd<sub>2</sub>O<sub>3</sub>.



**Fig. S6.** SEM images of (a) carboxylic acid-terminated silica, (b) core–shell of silica@GdCP, and (c) silica@Gd<sub>2</sub>O<sub>3</sub>. EDX spectra of (a') carboxylic acid-terminated silica and (b') silica@GdCP, and (c') silica@Gd<sub>2</sub>O<sub>3</sub>. (d) TEM image and (e) elemental line-scanning profiles of silica@Gd<sub>2</sub>O<sub>3</sub>.



**Fig. S7.** SEM images of (a) carboxylic acid-terminated silica, (b) core–shell of silica@GdCP, and (c) silica@GdCP@GdCP. EDX spectra of (a') carboxylic acid-terminated silica, (b') silica@GdCP, and (c') silica@GdCP@GdCP. (d) SEM image, (d') EDX spectrum, and (e) TEM image of core–shell-type metal oxide of silica@Gd<sub>2</sub>O<sub>3</sub>@Gd<sub>2</sub>O<sub>3</sub>.



**Fig. S8.** SEM images of (a) carboxylic acid-terminated silica, (b) core–shell of silica@GdCP, and (c) silica-templated CP double layer of silica@GdCP@ErCP. EDX spectra of (a') carboxylic acid-terminated silica, (b') silica@GdCP, and (c') silica@GdCP@ErCP. (d) SEM image, (d') EDX spectrum, and (e) TEM image of core–shell-type metal oxide double layers of silica@Gd2O\_3@Er\_2O\_3.



**Fig. S9.** SEM images of (a) carboxylic acid-terminated silica, (b) core–shell of silica@GdCP, and (c) silica-templated CP double layer of silica@GdCP@YCP. EDX spectra of (a') carboxylic acid-terminated silica, (b') silica@GdCP, and (c') silica@GdCP@YCP. (d) SEM image, (d') EDX spectrum, and (e) TEM image of core–shell-type metal oxide double layers of silica@Gd<sub>2</sub>O<sub>3</sub>@Y<sub>2</sub>O<sub>3</sub>.



**Fig. S10.** TGA curves of single-layered core–shell microspheres of (a) silica@ErCP, (b) silica@TbCP, (c) silica@YCP, and (d) silica@GdCP.



**Fig. S11.** TGA curves of double-layered core–shell microspheres of (a) silica@GdCP@ErCP and (b) silica@GdCP@YCP.



Scheme S1. Schematic representation for the construction of yolk–shell-type metal oxide double layers (silica@ $M_xO_y@M'_{x'}O_{y'}$ ) with various intervals between the yolk and shell metal oxide.



**Fig. S12.** Preparation of three different silica@ErCP@GdCP samples with various ErCP thicknesses. SEM images of (a) carboxylic acid-terminated silica, (b, b', b") three different silica@ErCP samples with ErCP thicknesses of 265, 435, or 570 nm, and (c, c', c") three different silica@ErCP@GdCP samples with varous ErCP thicknesses.



**Fig. S13.** Preparation of three different silica@TbCP@GdCP samples with various TbCP thicknesses. SEM images of (a) carboxylic acid-terminated silica, (b, b', b") three different silica@TbCP samples with TbCP thicknesses of 255, 435, or 550 nm, and (c, c', c") three different silica@TbCP@GdCP samples with various TbCP thicknesses.



**Fig. S14.** Preparation of yolk–shell-type metal oxide double layers (silica@Tb<sub>4</sub>O<sub>7</sub>@Gd<sub>2</sub>O<sub>3</sub>) with various intervals between the yolk and shell metal oxide. (a, a', a") SEM images of three different silica@TbCP@GdCP samples with various TbCP thicknesses of 255, 435, or 550 nm. (b, b', b") SEM images and (c, c', c") TEM images of the resulting yolk–shell-type metal oxide double layers of silica@Tb<sub>4</sub>O<sub>7</sub>@Gd<sub>2</sub>O<sub>3</sub>.